Effect of Nanocrystalline Diamond Films Deflection on Wear Observed in Reciprocating Sliding Tests

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Abstract: The present study deals with the tribological behavior of nanocrystalline diamond (NCD) films. The diamond films were deposited by microwave plasma enhanced chemical vapor deposition (MPCVD) in methane/hydrogen/air plasma on the Si(100) substrates. The tribological properties were studied by reciprocal sliding tests against Si₃N₄ balls. The depth profiles and surface morphology of the wear scars were investigated by means of mechanical profilometry and scanning electron microscopy (SEM). Various adaptation processes occur between contacting surfaces including asperity polishing, formation of carbonaceous tribolayer and ripple patterns on the wear scar surfaces. The film deflection is the specific form of adaptation decreasing contact pressure and, therefore, the damage (including wear) of both counter bodies. The deflection of NCD films in sliding tests can be related with the effect of fatigue.

1. INTRODUCTION

Diamond films are important engineering materials for tribological applications due to their outstanding properties including high hardness and Young’s modulus, chemical inertness and wear resistance. Diamond films are used for tools protection [1], in manufacturing of microelectromechanical systems (MEMS) [2], surgical instruments [3], etc. Investigation of tribological properties of diamond films has attracted much attention in the past. The mostly influential factors affecting tribological performance of diamond films are as follows: anisotropy of mechanical and tribological properties [4, 5], formation of amorphous carbonaceous lubricating tribolayer [6], ambient atmosphere [8, 9], surface morphology [10, 11], etc. Our previous studies [12-15] have reported the formation of morphological patterns on the wear scar surfaces including ripples and grooves after reciprocating sliding tests on nanocrystalline diamond (NCD) and microcrystalline diamond (MCD) films deposited on Si (100) substrates. In the context of the present study, it is worth mentioning that the ripples were already found during run-in period [12, 14, 15]. Among other effects, the morphological adaptation of the contacting surfaces of the tribosystem occurs at this friction stage [16]. Wear on diamond is a load dependent process [6], therefore an increase in the area of the contacting surfaces of the counterbodies reduces the wear. To summarize, material fracture, micro-ploughing and asperities polishing wear mechanisms [7, 10, 14, 15, 17], influence of ambient atmosphere [8, 9] on friction behavior and formation of carbonaceous tribolayer [7, 12] and morphological patterns [12-15] on the wear scar surfaces were observed during run-in period on the diamond films.

The tribological system under investigation can be viewed as a thin hard film on a soft substrate. The load-carrying capacity of the film/substrate system is an ability to withstand pressure in the system without loss of the system functionality. This parameter strongly influences tribological
behavior of the film/substrate system [18-20], however there is a lack of investigations of diamond films subjected to tribological contact [14, 15, 17]. The load-carrying capacity of the diamond like carbon (DLC)/substrate system depends on adhesion, internal stress, thickness and roughness of the film, hardness and Young's modulus of the film and substrate [20]. The load-carrying capacity of the film/substrate system is also a crucial aspect in understanding of the mechanics of plastic-elastic contact in nanoindentation measurements [21, 22].

The deflection of the NCD [14] and MCD [15, 17] films grown on the Si(100) substrates was observed after reciprocating sliding tests. The mechanisms underlying this phenomenon remain unclear. The properties of the substrate, diamond film and interface between them must be taken into account to realize the mechanisms contributing to the film deflection. It was suggested that following three factors could facilitate the Si(100) substrate deformation [14]. First, the dislocations network on the Si(100)/diamond film interface, which is formed during diamond film growth [23]. Second, the Si₃N₄ ball is placed in contact with the edges of sharp diamond grains at the beginning of the test, thus the local contact pressure between the grains and ball can be underestimated in calculations assuming the ball in contact with the plain surface. Third, these contact spots act also as so-called frictional hot-spots [24] and high local temperature at these spots can account for the Si substrate mechanical properties variation. It is also instructive to consider wear related phenomena on the different size scales [18].

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The aim of this systematic study is to investigate the influence of the load, test duration and film thickness on the deflection of NCD films in sliding tests. The study focuses also on the understanding of the correlation between the wear and film deflection.

The growth mechanisms and surface morphology of the NCD films used in the current study were investigated in our recent work [25]. It was found that the surface morphology changes from the cusp-like to mountain-like and the surface roughness increases with increasing film thickness.

2. EXPERIMENTAL

The diamond films were deposited on Si(100) substrates in a microwave plasma CVD system ARDIS-100 (2.45 GHz, 5 kW) using a CH₄/H₂/air mixture as the process gas, for the details of deposition see our publication [25]. The film thicknesses were 2.7, 4.8, 9 and 22 μm and the surface roughness S₄ (root-mean-square) of the films was 55, 62, 63 and 99 nm, respectively.

Reciprocating sliding tests (normal load 0.5-3 N, displacement amplitude 1 mm, frequency 5 Hz, relative humidity about 50 %, ball diameter Ø 3 mm) were carried out by means of a CETR® UMT-2 tribometer. The test durations were 9000, 36000 and 72000 cycles. Si₃N₄ balls (surface roughness Rₐ = 0.012 μm) (REDHILL®) were used as counter bodies. According to the producer provided data, the hardness, Young's modulus and Poisson ratio of the Si₃N₄ counter bodies were 1400-1700 HV, 310 GPa and 0.27, respectively. Monocrystalline Si (100) possesses a hardness of about 12 GPa [26]; due to crystal anisotropy its Young's modulus varies along the (100) plane from about 130 [27] to 170-180 GPa [26, 27], the Poisson ratio is 0.278 [28], the fracture strength measured on Si (100) wafers is about 6.1 GPa [29].

Wear scars depth profiles were taken by stylus profilometry (Mahr Perhometer measuring system). Scanning electron microscopy (SEM) images were taken by a Zeiss EVO® MA-15 system with LaB₆ cathode in secondary electron mode, applying an accelerating voltage of 10 - 15 kV and 6.5 - 8.5 mm working distance.

The micro-Raman measurements were carried out on a Renishaw inVia micro-Raman setup equipped with an Ar+ ion laser (514 nm wavelength).

3. RESULTS AND DISCUSSION

Figure 1 shows the coefficient of friction (COF) versus number of cycles curves. In the case of the tests with 0.5 N, there are no considerable differences in friction behavior between 2.7, 4.8 and 9 μm thick films, i.e. a steady state regime with the COF value about 0.13 - 0.16 was observed after a transient period. Due to the relatively high roughness of the 22 μm thick film, the run-in period is substantially longer for the test with 0.5 N in contrast to one with 2 N. For the tests performed at higher loads (2 and 3 N), a wider variability of COF values was found in the steady-state wear regime depending on the film thickness, see Figure 1b. The highest COF value in the steady-state regime was observed for the smoothest and thinnest 2.7 μm thick film, i.e. about 0.2 for the test with 2 N. An exfoliation (catastrophic wear) of this film was observed in the tests with the load of 3 N and the duration longer than 3000 cycles.

Figure 2 shows SEM images taken on the surface of as-deposited 22 μm thick NCD film (Figure 2a) and wear scar surfaces after the tests with the load of 0.5 N (Figure 2b-d). The surface asperities are gradually smoothed with increasing number of cycles from 36000 to 72000 cycles. The unpolished surface of the pristine diamond film still can be seen after the test with 72000 cycles. Ripple patterns can be observed on the surface after the test with 72000 cycles, in agreement with our previous studies [12-15].
Figure 1: COF versus number of cycles curves corresponding to the tests with 0.5 N (a) and 2 N (b).

Figure 2: Surface morphology of the as-deposited 22 µm thick NCD film (a) and the wear scars after the tests with the load of 0.5 N and the sliding durations of 36000 cycles (b) and 72000 cycles (c, d).

The transverse depth profiles were measured at 5 different locations on each wear scar after sliding tests with different loads and durations. The line scans shown in Figure 3 are obtained by averaging 5 depth profiles. The film deflection phenomenon can be understood by the analysis of SEM and profilometry data shown in Figures 2 and 3. The approximate position of the film surface shown in Figure 2d is depicted by a rectangular in Figure 3. The level of the border of the wear scar bed lies well below the level of the border of the most low-lying valleys of the pristine NCD film surface (Figure 3). It indicates that a part of the unpolished NCD film surface seen in Figure 2d is located below the level of the pristine NCD film surface. The film deflection value (Δ) is shown in Figure 3b for the test with 72000 cycles. The pristine surface of the NCD films within the wear scars was observed after the tests with 9000 cycles, it enables to compare the deflection of films with different thicknesses (Figure 4). The smallest film deflection was observed for the 9 and 22 µm thick films after the test with 0.5 N. The Δ value increases with increasing load. It could be expected that the Δ value for the thicker films should be smaller than that for the thinner ones, due to higher load-carrying capacity of the thicker films [20]. No clear evidence of such trend was found (Figure 4), likely due to insufficient film thickness. However, an analysis of the shape of the wear scar profiles in Figure 3 provides an evidence of higher load-carrying capacity of the thicker films. The wear scar profile shapes tend to become more broader for the 22 µm thick film and more deeper for the 4.8 µm thick film for the same value of load. This finding could be a consequence of the bending of films in the course of sliding, i.e. the thinner films are bended more strongly than the thicker ones, see Inserts in Figure 3a and b. The higher COF value for 2.7 µm thick film observed in tests with 2 N (Figure 1b) can be explained by film bending resulting in a higher contact area...
between the counterbodies [19, 20]. The aforementioned exfoliation of the 2.7 µm thick films confirms also the lower load-carrying capacity of the thinner films. In other words, in analogy with nanoindentation measurements, elastic and plastic parts of deformation of the film/substrate system need to be taken into account to explain the film deflection phenomenon. Moreover, a higher Δ value was found after long-duration tests (0.5 N, 36000 and 72000 cycles) on the 22 thick film (Figure 4), thus a fatigue damage occurs in the diamond film/Si substrate tribosystem. The structural peculiarities of the diamond film/Si substrate system are shown in Figure 5. The dislocations network and hot-spots were discussed in Introduction. Following the publications by Williams et al. [30], Williams [31] and Setasuwon and Metanawin [32], a structure at the interface between the diamond film and the Si substrate is schematically shown in Figure 5. The properties of the diamond film structure formed during the early stage of the film growth can differ from those of the core part of diamond film. For instance, the diamond film surface asperities fracture occurs during the run-in period. By analogy, the structure formed on the interface may not withstand the pressure in the system and may be

![Figure 3: Depth profiles taken across the wear scars.](image-url)

![Figure 4: Film deflection value (Δ) measured after the tests with 9000 cycles for different loads. The Δ value is also shown for the tests with the load of 0.5 N (36000 and 72000 cycles) for the 22 µm thick film, because the pristine film surface was observed. The error bars correspond to standard deviation.](image-url)
Effect of Nanocrystalline Diamond Films Deflection on Wear Observed

On the other hand, a relatively small contact area between the seeding particles (the contact spots between the substrate and film in Figure 5) and the Si substrate can strongly influence contact pressure between the diamond films and substrate leading to deformation of the Si substrate.

Figure 5: Model of the diamond film/Si substrate tribosystem.

The wear rate is calculated according equation \( W = \frac{V}{F \times L} \), where \( V \) is the wear volume loss, \( F \) the normal load and \( L \) the sliding distance. In the present study, the wear is affected by the film deflection, i.e. aforementioned equation, in principle, is not applicable for the calculation of wear rate of the diamond films and balls. Indeed, a fraction of the scar volume corresponding to the wear volume loss must be distinguished from a fraction related to the effect of film deflection. In addition, an interconnection between two processes leading to these effects should be taken into account i.e. mechanisms contributing to the film deflection can influence on the mechanisms contributing to the wear volume loss. For instance, a faster increase in the contact surface area during film deflection process can result in a greater decrease in the contact pressure and therefore slower material removal rate. In other words, the wear volume loss can differ for tribological systems with or without deflection. For the sake of comparison with data from literature, damage parameters (\( W_D \) and \( W_B \)) were calculated for the NCD films and Si\(_3\)N\(_4\) balls using wear rate equation. The value of \( W_D \) calculated for the tests with the higher loads (2 and 3 N) and longer duration (36000-72000 cycles) is about 1.5 ± 0.5 - 4.5 ± 1.2 \( \times 10^{-7} \) mm\(^3\)/Nm, which is similar to the value calculated according wear rate equation for NCD films and reported by Erdemir et al. [9, 11]. In the case of MCD films, similar values were found in our studies [15, 17]. It is important to stress that the type of measurement (diamond film, ball, substrate and tribological test conditions) in the mentioned studies [9, 11] was similar to the present one. The damage parameter for Si\(_3\)N\(_4\) balls was about 1 ± 0.3 \( \times 10^{-7} \) mm\(^3\)/Nm for the longer duration tests and similar value was found in the study [9]. The measurement uncertainty (standard deviation) was evaluated, the sample size was 3 scars (balls) produced with the same test parameters. Thus, the similarity between results indicates that the wear of the NCD films [9] could be affected by the film deflection as well.

Formation of carbonatious tribolayer was observed during run-in period (Figure 6a). The details of the Raman peaks identification can be found in our publications [12, 25]. The peak at 1540 cm\(^{-1}\) (G bands) corresponds to the in-plane stretching of sp\(^2\) bonds. A decrease of the diamond/sp\(^2\) (G) peak intensity ratio for the wear scar surfaces allows to conclude that a stress-induced transition of diamond to sp\(^2\) bonding takes place, i.e. self-lubrication occurs in sliding tests, in agreement with previous study [12]. In addition, the surface smoothing and diamond films deflection reduce the contact pressure and wear of both mating surfaces. The EDS spectrum shows a relatively weak Si signal indicating wear of Si\(_3\)N\(_4\) balls (Figure 6b). On the other hand, the results can be formulated in terms of entropy-based concept [33, 34]. The wear and friction are irreversible processes, however, because both are non-equilibrium processes self-organization.

Figure 6: Raman spectra a) taken on the pristine 22 \( \mu \)m thick film surface and the wear scar surface after the test with 0.5 N (72000 cycles). The diamond/sp\(^2\) (G) peak intensity ratios derived from the Raman spectra. EDS spectrum b) was taken on the wear scar of 22 \( \mu \)m thick film after the test with 0.5 N (72000 cycles).
can already occur in system during run-in period, which minimizes entropy production rate (or wear and friction). In the broader context, the formation of tribolayer and morphological patterns [33], as well as the asperities smoothening and the film deflection can be viewed as self-organization processes or mutual adjustment of the surfaces in tribosystem. Finally, it is interesting to note that the asperities smoothening and the surface deflection occur on the micro and macro levels, respectively.

Additional studies should be conducted to investigate the influence of the film deflection to the formation of ripples patterns on the wear scar surfaces. It was shown that the load value affects to the shape and size of the ripples [13].

CONCLUSIONS

The study focuses on the influence of diamond films deflection on the tribological properties. The deflection of NCD films was found after the sliding tests with different loads and durations. The film deflection is fatigue-induced evolution of the film structure and shape. The formation of the carbonotribic layer indicates self-organization in tribosystem. The contact pressure decreases due to smoothening of the contacting surfaces and film deflection. These facts indicate the adaptation of mating sliding surfaces. The development of a more complete model for the wear rate calculation of the systems exhibiting different adaptation mechanisms is a challenge for the next researches.

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REFERENCES


